

INVESTIGATION OF TERNARY  
SEMICONDUCTING SYSTEM  $(Al_xIn_{1-x})_2Se_3$

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Abstract:

A series of samples in the system  $Al_2Se_3$ - $In_2Se_3$  have been synthesized and studied. The interval of the Al/In (molar) Ratio  $r$  from  $r \geq 0,02$  to  $r \leq 0,05$  has been two phase region  $\alpha$  and  $\beta_1$ . For  $r > 0,05$  ternary,  $\beta_1$  alloys  $(Al_xIn_{1-x})_2Se_3$  have been present alone, and their unit cell parameters have decreased continuously as the Al content increased. The samples have also been studied by differential thermal analysis. Results of the optical and electrical conductivity measurements are presented.

A series of samples in the system  $Al_2Se_3$ - $In_2Se_3$  have been synthesized, firstly in the In-rich region, and then gradually increasing the Al content. All the crystals were prepared by the modified SSD (Synthesis, solute diffusion) method<sup>(1)(2)</sup>. Selen, as the element with high vapour pressure was placed in the evacuated reaction vessel at 990 K, so that the resulting partial pressure was about  $1,5 \cdot 10^5$  Pa. The mixture of Al and In (purity 6 N) in exact stoichiometric proportion for a given  $x$ , was in an alumina crucible in the upper part of a vessel, in a temperature gradient of approximately  $50 K cm^{-1}$ , around 1150 K. Se evaporated and diffused into the melted Al + In. As the temperature at the bottom of the crucible was chosen to be somewhat lower than the expected melting point of the finished ternary compound, the crystallization started there. The reaction was completed in 5-7 days.

The crystals obtained were mostly compact, polycrystalline ingots with colour changing, from black-greyish to dark-red, reddish, orange and yellow with the increase of the

Al content. The crystals with 60 % and 88 % of Al were not stable and in contact with air quickly decompose into the red powder.

The structural properties of the samples were studied by the X-ray diffraction analysis. The dependence of normalized unit cell parameters  $a_N$  and  $c_N$  on the concentration of Al,  $x$ , is shown on Fig. 1. For  $x=0$ , the black alloy obtained has been  $\alpha$ , rhombohedral,  $\text{In}_2\text{Se}_3$ ; the same phase was obtained by the usual direct synthesis of In and Se in exact stoichiometric amounts<sup>(3)</sup>. The addition of even very small amounts of Al ( $x = 0,02$  and  $x = 0,04$ ) produced the samples which were mixture of  $\alpha$  and  $\beta_1$  phase.  $\beta_1$  phase is isostructural with the second high temperature modification,  $\beta'$ , of  $\text{In}_2\text{Se}_3$ . The unit cell parameters of  $\alpha$  and  $\beta_1$  phases in this two-phase region, practically have not changed with the Al content, the parameters of  $\alpha$  being equal to the values for  $\alpha$   $\text{In}_2\text{Se}_3$ . The increase of the Al content results only in different fractions of  $\alpha$  and  $\beta_1$  phases, namely, for  $x = 0,02$  the fractions of  $\alpha$  and  $\beta_1$  phases have been similar, but in the samples for  $x = 0,04$ , the  $\beta_1$  phase has been dominant with about 1 %  $\alpha$  phase. For greater Al contents ( $x \geq 0,14$ ) the samples have been homogeneous ternary alloys  $(\text{Al}_x\text{In}_{1-x})_2\text{Se}_3$  designated as  $\beta_1$ . The unit cell parameters of this ternary alloys have decreased continuously as the concentration of Al increased.

Data for  $x = 0,6$  and  $x = 0,88$  have not been presented, as the instability of compounds caused great experimental errors.

Differential thermal analysis agrees with the X-ray diffraction data. The dependence of the melting point of the synthesized samples on the Al concentration  $x$  is shown on Fig. 2. For  $x=0$ , obtained signal at 1150 K represents the melting point of  $\text{In}_2\text{Se}_3$ . For  $x = 0,02$ , beside 1150 K signal, there is another signal at 1115 K which corresponds to the melting point of  $\beta_1$  phase. The same situation is for  $x = 0,04$ , but for the samples with higher contents of Al ( $x \geq 0,14$ ) the system become mono-phase, the only value for melting point is 1115 K within the limits of experimental error.

On Fig. 3. the results of optical measurements on the samples  $x = 0,04$ ,  $x = 0,14$ ,  $x = 0,33$  and  $x = 0,45$  are shown. The abrupt change in the absorption coefficient  $\alpha$  represents the effect of direct electronic

transitions from the valence band to the conduction band. As the samples have been polycrystalline, the absorption at the grain boundaries is very strong so that the absorption coefficient is too high even in the region of transparency and it cannot be said anything positive about indirect transitions. From the  $(\alpha h\nu)^{2/3}$  vs.  $h\nu$  representation, the width of the forbidden energy gap has been estimated:

$$\begin{array}{llll} x = 0.04 & E_g = 1.8 \text{ eV} , & x = 0.14 & E_g = 2.0 \text{ eV} , \\ x = 0.33 & E_g = 2.2 \text{ eV} , & x = 0.45 & E_g = 2.3 \text{ eV} . \end{array}$$

Electrical conductivity measurements have also shown prevailed dependence on the Al content. The samples with small percentage of Al ( $x=0$ ,  $x = 0.02$ ,  $x = 0.04$ ) had relatively low resistance at room temperature, order of magnitude  $10^6 \Omega \text{ cm}$ , while for the samples  $x \geq 0.14$  the resistance has been about  $10^{12} \Omega \text{ cm}$ .

For thermal stability investigation and controllable structural defects introduction for identification and investigation, the crystals have been annealed several times at  $250^\circ\text{C}$ ,  $350^\circ\text{C}$ ,  $450^\circ\text{C}$ ,  $525^\circ\text{C}$  and  $650^\circ\text{C}$ , for 30 min. The samples with higher Al contents have shown greater thermal stability and the significant increase in conductivity does not appear until annealing at  $525^\circ\text{C}$ .

Using thermoelectric probe it has been noticed that all the annealed compounds, with sufficiently lowered electrical resistivity, are n-type.

Fig. 4. represents temperature dependence of the conductivity after annealing at  $650^\circ\text{C}$ . All the defects for which the energy levels can be determined or anticipated from the slope of  $\log \sigma$  vs.  $1/T$  curves are thermally generated defects induced while the samples were annealed at high temperatures. As the high temperature annealing is accompanied with strong Se evaporation, and colour change of crystals from transparent red to a opaque black, it is reasonable to expect that the thermally induced defects correspond to singly or multiply ionized Se vacancies.

References:

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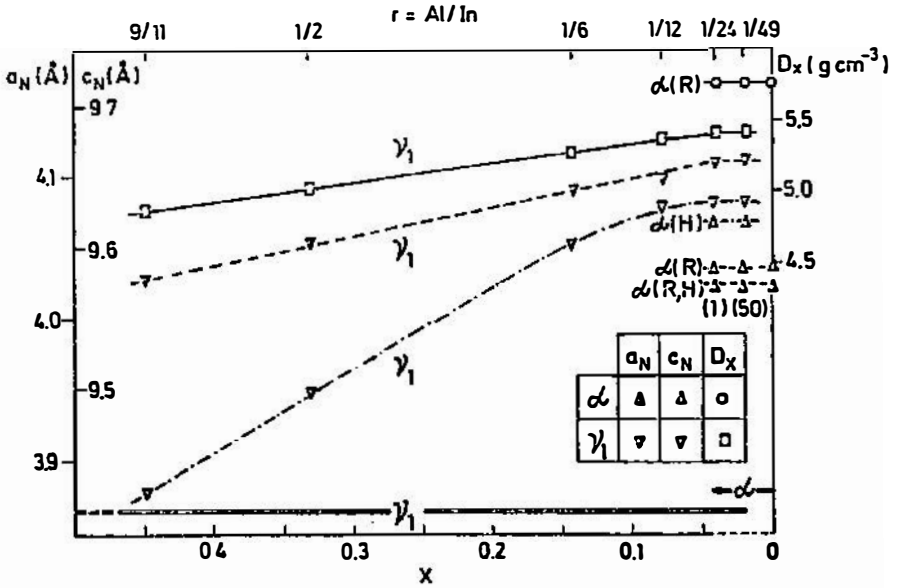


Fig.1

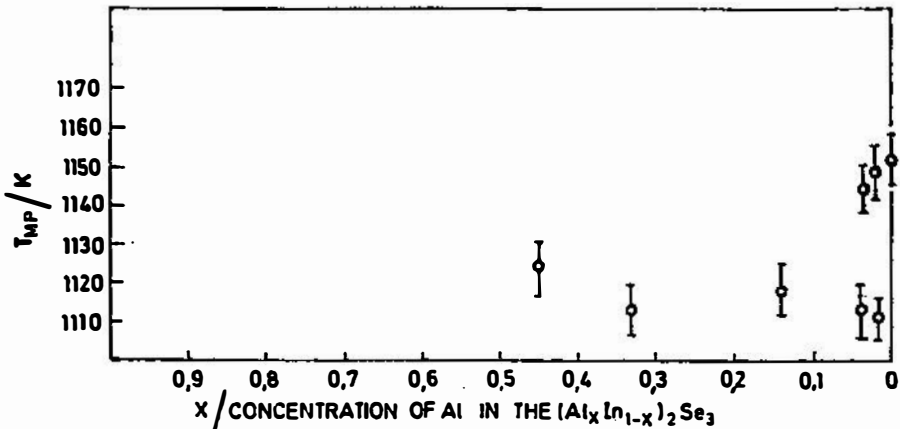


Fig.2

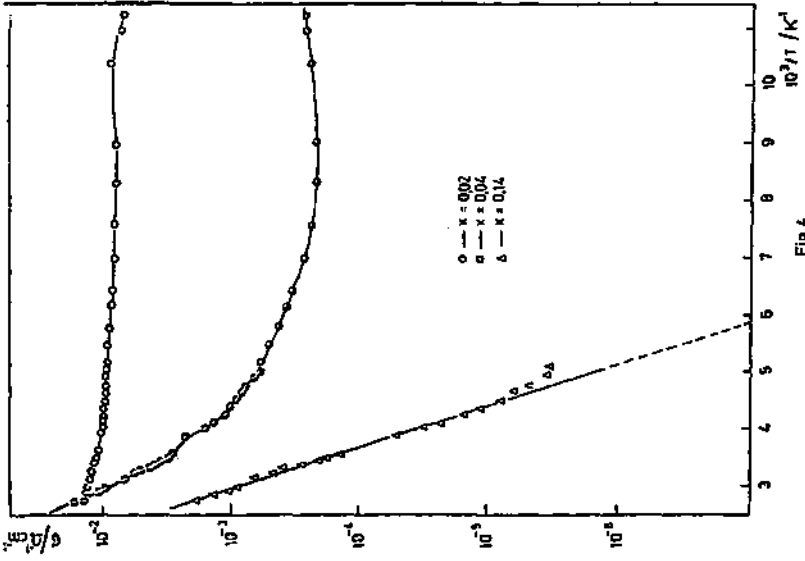


Fig.4

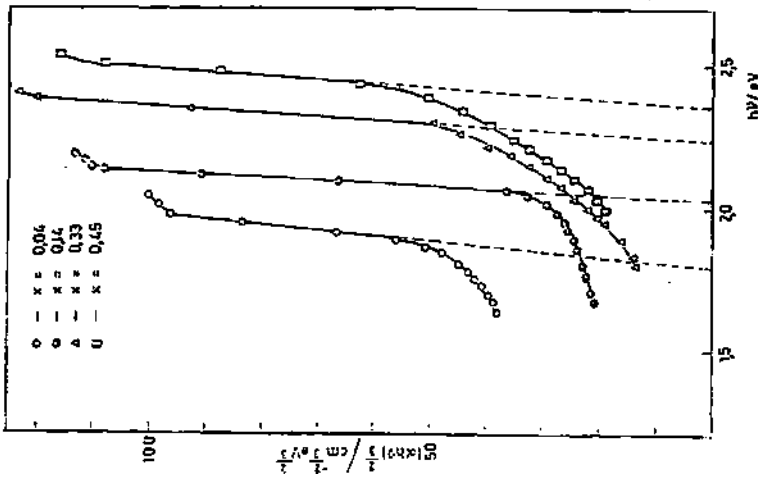


Fig.3